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EUROPEAN PATENT APPLICATION

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⑤① Int. Cl.4: **B 22 D 11/00, B 22 D 11/06**

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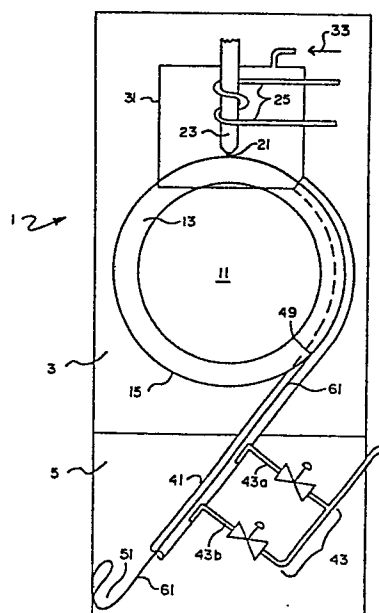
⑧④ Designated Contracting States: **BE DE FR GB IT**

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⑤④ **Method of forming disordered filamentary materials.**

⑤⑦ Disclosed are method and apparatus for quenching materials, where the quench duration is enhanced by providing a high speed gas jet (43) tensioning force beyond the intended point of ribbon take off.





European Patent
Office

EUROPEAN SEARCH REPORT

0183220

Application number

EP 85 11 4956

DOCUMENTS CONSIDERED TO BE RELEVANT			
Category	Citation of document with indication, where appropriate, of relevant passages	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl.4)
Y,D	US-A-3 862 658 (BEDELL et al.) * Abstract; figure 1; page 3, lines 37-64 *	1	B 22 D 11/00 B 22 D 11/06

Y,D	US-A-4 077 462 (BEDELL et al.) * Abstract; figure 1; column 5, line 63 - column 6, line 21 *	1	

A	US-A-3 863 700 (BEDELL et al.)		

A	DE-A-2 809 837 (THE FURUKAWA ELECTRIC)		

A	FR-A-2 471 824 (HITACHI)		

The present search report has been drawn up for all claims			TECHNICAL FIELDS SEARCHED (Int. Cl.4)
			B 22 D
Place of search THE HAGUE		Date of completion of the search 21-05-1987	Examiner OBERWALLENEY R.P.L.I
CATEGORY OF CITED DOCUMENTS X : particularly relevant if taken alone Y : particularly relevant if combined with another document of the same category A : technological background O : non-written disclosure P : intermediate document T : theory or principle underlying the invention E : earlier patent document, but published on, or after the filing date D : document cited in the application L : document cited for other reasons & : member of the same patent family, corresponding document			